

PATENT
0171-1098PUS1

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Takeru WATANABE, et al. Conf.:
Appl. No.: NEW Group:
Filed: May 20, 2004 Examiner:
For: BASIC COMPOUND, RESIST COMPOSITION AND
PATTERNING PROCESS

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

May 20, 2004

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

This amendment includes: Amendments to the Specification and Remarks.